IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Jiang et al. Art Unit:

1765

Serial No.:

09/966.605

Examiner:

Vinh, L.

Filing Date:

09/28/2001

Docket No.: TI-31462

Title:

IN-SITU PLASMA ASH/TREATMENT AFTER VIA ETCH OF

LOW-K FILMS FOR POISON-FREE DUAL DAMASCENE

TRENCH PATTERNING

Amendment

Assistant Commissioner of Patents

PO Box 1450

Alexandria, VA 22313-1450

June 12, 2003

CERTIFICATION OF FACSIMILE TRANSMISSION

I hereby certify that the following papers are being transmitted by facsimile to the U.S. Patent and Trademark Office at

703-872-9318 on the data shown below:

eline J. Garner, Reg. No. 36,144

September 9, 2003 Date

Dear Sir:

The following amendments and remarks are offered in response to the Examiner's Office Action dated 04/09/2003. They are respectfully submitted as a full and complete response to that Action.

There are no Amendments to the Specification.

Amendments to the Claims are reflected in the listing of claims that begin on page 3 of this paper.

There are no Amendments to the Drawings.

The **Remarks** begin on page 6.